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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/613,069	07/07/2003	Hiroyuki Kunishima	NE-70085US	8547	
21254	11/10/2004		EXAMINER		
MCGINN & GIBB, PLLC 8321 OLD COURTHOUSE ROAD SUITE 200 VIENNA, VA 22182-3817			HUYNH,	HUYNH, ANDY	
			ART UNIT	PAPER NUMBER	
			2818		
			DATE MAILED: 11/10/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/613,069	KUNISHIMA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Andy Huynh	2818				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) day ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 28 October 2004.						
This action is FINAL . 2b)⊠ This action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1-51</u> is/are pending in the application.						
4a) Of the above claim(s) <u>1-34</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
· <u> </u>	6) Claim(s) 35-51 is/are rejected.					
7) Claim(s) is/are objected to.	alastian rasuiromant					
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examine	r.					
10)⊠ The drawing(s) filed on <u>07 July 2003</u> is/are: a)□ accepted or b)⊠ objected to by the Examiner.						
Applicant may not request that any objection to the c	* '					
Replacement drawing sheet(s) including the correcti	•	•				
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Office	ACION OF IOTH PTO-132.				
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreign a)⊠ All b)□ Some * c)□ None of:)-(d) or (f).				
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents						
 Copies of the certified copies of the prior application from the International Bureau 	•	ed in this National Stage				
* See the attached detailed Office action for a list of		ed.				
Attachment(s)						
Notice of References Cited (PTO-892)	4) Interview Summary					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	ate Patent Application (PTO-152)				
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>07/07/03</u> .	6) Other:					
		<u>, ,</u>				

Election/Restrictions

In the Response to the Restriction Requirement dated October 28, 2004, Applicant has elected the invention of Group II, claims 35-51 drawn to a device, without traverse is acknowledged. Accordingly, claims 1-34 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 35 § 1.142(b) and MPEP § 821.03. Applicant has the right to file a divisional application covering the subject matter of the non-elected claims 1-34.

Priority

Acknowledgment is made of applicant's claim for foreign priority under 35 U.S.C. 119(a)-(d) based on an application filed in JAPAN, 2002-198432 on 07/08/2002.

Information Disclosure Statement

This office acknowledges receipt of the following items from the applicant: Information Disclosure Statement (IDS) filed 07/07/2003 and 09/02/2003. The references cited on the PTOL 1449 form have been considered.

Drawings

The drawings are objected for the following reason.

Figures 1a-1b should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g).

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Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 45-47 are rejected under 35 U.S.C. § 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 45 and 47 recite the limitation "... the identical interconnect layer ..." there is insufficient antecedent basis for this limitation in the claims.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

Claims 35-44, 48 and 49 are rejected under 35 U.S.C. 102(e) as being anticipated by Uzoh et al. (USP: 6,465,376 hereinafter referred to as "Uzoh").

Regarding claim 35, Uzoh discloses in Figs. 6 and 7 and the corresponding texts as set forth in column 2, line 53-column 4, line 26, a semiconductor device comprising:

a semiconductor substrate (1); and

a dissimilar element-diffused metal layer (8) formed on said semiconductor substrate, containing copper (Cu) and a dissimilar element (Cu alloy) other than copper and having a generally uniform orientation at a surface thereof (col. 3, lines 7-11).

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Regarding claim 36, Uzoh discloses in Figs. 6 and 7 and the corresponding texts as set forth in column 2, line 53-column 4, line 26, a semiconductor device comprising:

a semiconductor substrate (1); and

a dissimilar element-diffused metal layer (8) formed on said semiconductor substrate, containing copper (Cu) and a dissimilar element (Cu alloy) other than copper, constituted of grains of an average size not less than 1 µm (col. 4, lines 12-17).

Regarding claims 37 and 38, Uzoh discloses the semiconductor wherein an average grain size of crystals of said dissimilar element-diffused metal layer is greater than an average thickness of said dissimilar element-diffused metal layer (col. 4, lines 12-26).

Regarding claims 39 and 40, Uzoh discloses the semiconductor wherein a surface of said dissimilar element-diffused metal layer has an orientation of (200). It is inhering that after annealing at a desired temperature or heat treatment a surface of said dissimilar element-diffused metal layer would result in having an orientation of (200) (col. 3, lines 22-25).

Regarding claims 41 and 42, Uzoh discloses in Figs. 6 and 7 the semiconductor device wherein said dissimilar element-diffused metal layer constitutes an interconnect (8), a plug or a pad.

Regarding claims 43 and 44, Uzoh discloses the semiconductor wherein said dissimilar element-diffused metal layer is formed by plating (col. 3, line 9).

Regarding claim 48, Uzoh discloses in Figs. 6 and 7 and the corresponding texts as set forth in column 2, line 53-column 4, line 26, a metal interconnect constituted of a plated metal layer (8) comprising a plurality of dissimilar elements (Cu alloy), wherein an average size of grains contained in said plated metal layer is not less than 1 µm (col. 4, lines 12-17).

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Regarding claim 49, Uzoh discloses in Figs. 6 and 7 and the corresponding texts as set forth in column 2, line 53-column 4, line 26, a metal interconnect constituted of a plated metal layer (8) comprising a plurality of dissimilar elements (Cu alloy), wherein said plated metal layer is constituted of a single grain.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 50 and 51 are rejected under 35 U.S.C. 103(a) as being unpatentable over Uzoh et al. (USP: 6,465,376 hereinafter referred to as "Uzoh").

Uzoh discloses the claimed limitations except for the metal interconnect having a width not less than 1 μ m. It would have been obvious to one having ordinary skill in the art at the time of the invention was made to form the metal interconnect having a width not less than 1 μ m, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

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Conclusion

A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andy Huynh, (571) 272-1781. The examiner can normally be reached on Monday-Friday from 8:30 AM to 5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The Fax number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the -status of this application or proceeding should be directed to the receptionist whose phone number is (703) 308-0956.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Andy Huynh

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11/08/04

Patent Examiner